

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/014,131	12/13/2001	Toshikazu Onishi	35.C13314 D2	3837
5514 7	590 08/20/2004	EXAMINER		
FITZPATRIC 30 ROCKEFEI	K CELLA HARPER	SANTIAGO, MARICELI		
NEW YORK, NY 10112			ART UNIT	PAPER NUMBER
·			2879	

DATE MAILED: 08/20/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

PTO-90C (Rev. 10/03)

		Application	on No.	Applicant(s)	£ N C			
Office Action Summary		10/014,13	1	ONISHI ET AL.	Or			
		Examiner		Art Unit				
		Mariceli S	antiago	2879				
The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply								
THE - External formal f	ORTENED STATUTORY PERIOD FOR IMAILING DATE OF THIS COMMUNICAT asions of time may be available under the provisions of 37 SIX (6) MONTHS from the mailing date of this communicat period for reply specified above is less than thirty (30) day period for reply is specified above, the maximum statutory re to reply within the set or extended period for reply will, be reply received by the Office later than three months after the patent term adjustment. See 37 CFR 1.704(b).	TION. CFR 1.136(a). In no evention. s, a reply within the state period will apply and will state to state the apply statute, cause the apply statute, cause the apply statute.	ent, however, may a reply be time story minimum of thirty (30) day: I expire SIX (6) MONTHS from ication to become ABANDONE	nely filed s will be considered timely. the mailing date of this comr D (35 U.S.C. § 133).	nunication.			
Status								
1)⊠	Responsive to communication(s) filed or	1 <u>21 April 2004</u> .						
	This action is FINAL . 2b)⊠ This action is non-final.							
3)□	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.							
Dispositi	on of Claims							
5)□ 6)⊠ 7)□	 4) Claim(s) 16-25 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 16-25 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 							
Applicati	on Papers							
10)⊠	The specification is objected to by the Ex The drawing(s) filed on <u>13 December 200</u> Applicant may not request that any objection Replacement drawing sheet(s) including the The oath or declaration is objected to by	01 is/are: a)⊠ ac to the drawing(s) b correction is require	e held in abeyance. See ed if the drawing(s) is ob	e 37 CFR 1.85(a). jected to. See 37 CFR	1.121(d).			
Priority ι	ınder 35 U.S.C. § 119							
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 09/248,102. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 								
Attachmen								
2) Notice 3) Information	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-9 mation Disclosure Statement(s) (PTO-1449 or PTO r No(s)/Mail Date	•	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ate	52)			

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on December 4, 2004 has been entered.

Response to Amendment

The Amendment, filed on April, 21, 2004, has been entered and acknowledged by the Examiner.

Cancellation of claims 1-15 has been entered.

Claims 16-25 are pending in the instant application.

Specification

The substitute specification filed December 13, 2001 has not been entered because it does not conform to 37 CFR 1.125(b) and (c) because:

The statement as to a lack of new matter under 37 CFR 1.125(b) is missing.

The current status of all nonprovisional parent applications referenced should be included. Reference to prior art applications should be updated to recite "This is a divisional of U.S. Patent Application No. 09/848,360, filed on May 4, 2001, **now U.S. Patent No.** 6,379,211..."

Application/Control Number: 10/014,131

Art Unit: 2879

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 16-25 are rejected under 35 U.S.C. 103(a) as being unpatentable over Ikeda et al. (US 5,591,061) in view of Yamanobe (EP 0 788 130).

Regarding claims 16-18, Ikeda discloses a method of manufacturing an electron source comprising the steps of exposing a surface of a substrate to a sealed atmosphere, on which a plurality of electron-emitting devices are formed, and introducing a gas containing carbon into the sealed atmosphere (Column 11, lines 51-67), wherein the sealed atmosphere is formed by a chamber. Ikeda discloses "The vacuum chamber was so operated by the control unit **55** that, after evacuating the vacuum chamber by means of an ion pump to about 10⁻⁶ Pa, acetone was introduced into the chamber by regulating a gas supply unit **51** and a solenoid valve **52** until the inner pressure of the vacuum chamber rose to 2.7 x 10⁻¹ Pa. At the same time, the drive circuit of the vacuum pump unit was also operated by the control unit **55** to regulate the evacuation rate by means of a gate valve.", (Column 26, lines 22-31). Accordingly, as clearly stated by Ikeda, the introducing of gas containing carbon is performed while exhausting the sealed atmosphere formed by the camber.

Ikeda discloses the step of heating the chamber at prior to the activation step (Column 13, lines 11-19) but fails to particularly disclose heating the chamber prior the introducing step. However, in the same field of endeavor, Yamanobe discloses a method of manufacturing an electron source comprising the step of activating the emitter source comprising coating the emitter with a carbon material and causing a current to energize the electro-conductive member.

Application/Control Number: 10/014,131

Art Unit: 2879

Yamanobe discloses that water vapor causes non-uniform results in the activation process.

Since a non-uniform display is undesirable, it would have been obvious to one of ordinary skill in the art at the time of applicants' invention to remove the water vapor before an activation step, whether the carbon is introduced as a gas or otherwise. Accordingly, it would have been obvious to one of ordinary skill in the art at the time of invention was made to heat the chamber of lkeda prior to introducing the carbon gas to remove the water vapor so to obtain more uniform results in the activation process since Yamanobe teaches that water vapor undesirably affects the activation process.

Regarding claim 19, Ikeda discloses a method further comprising the step of applying a voltage to an electro-conductive member, the electro-conductive member being disposed on the surface of the substrate (Abstract).

Regarding claim 20, claim 20 is rejected for the same reasons stated in the rejection of claim 1 above, furthermore, Ikeda discloses wherein an electro-conductive member, in which an electron-emitting region is formed, being disposed on the surface of the substrate (Abstract).

Regarding claim 21, Ikeda discloses a method further comprising the step of applying a voltage to the electro-conductive member (Abstract).

Regarding claims 22 and 24, claims 22 and 24 are rejected for the same reasons stated in the rejection of claim 1 above, furthermore, Ikeda discloses an electro-conductive member, capable of being subjected to an activation of an electron-emitting function, being disposed on the surface of the substrate (Abstract).

Regarding claims 23 and 25, Ikeda discloses a method further comprising the step of applying a voltage to the electro-conductive member (Abstract).

Application/Control Number: 10/014,131

Art Unit: 2879

Contact Information

Page 5

Any inquiry concerning this communication or earlier communications from the examiner

should be directed to Mariceli Santiago whose telephone number is (571) 272-2464. The

examiner can normally be reached on Monday-Friday from 9:30 AM to 6:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's

supervisor, Nimesh Patel, can be reached on (571) 272-2457. The fax phone number for the

organization where this application or proceeding is assigned is (703) 872-9306.

Information regarding the status of an application may be obtained from the Patent

Application Information Retrieval (PAIR) system. Status information for published applications

may be obtained from either Private PAIR or Public PAIR. Status information for unpublished

applications is available through Private PAIR only. For more information about PAIR system,

see http://pair-direct.uspto.gov. Should you have questions on access to Private PAIR system,

contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

(WMz) श्रीनेश्म Mariceli Santiago Patent Examiner Art Unit 2879